

- Silver Metallization
 - Consumption and Costs
 - Screen Printable Air Fired
- Why Not Copper
 - Issues oxidation, diffusion
 - Previous approaches
- The Bert Thin Film Approach
 - Screen Printable Air fired
 - Paste
 - Screen Printing
 - Performance
 - Durability
- Conclusions



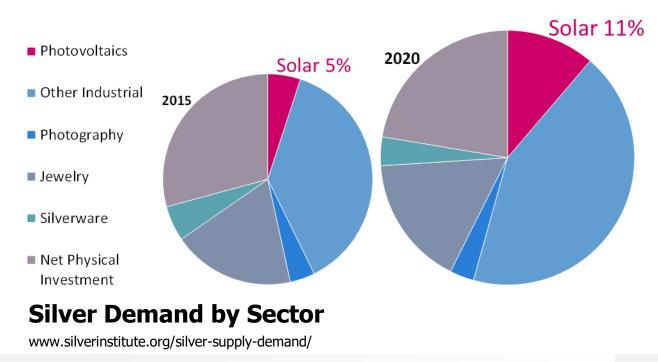
Copper is 800 times more abundant than Silver.

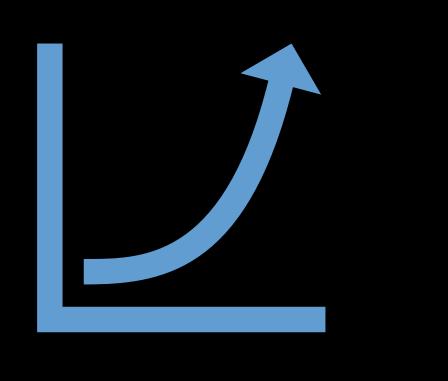
Metallization

A small part of the cell, but a critical part of the performance and cost

Scaling solar to meet the global need for electricity would push the photovoltaic industry to demand all of the silver production at current silver usage.

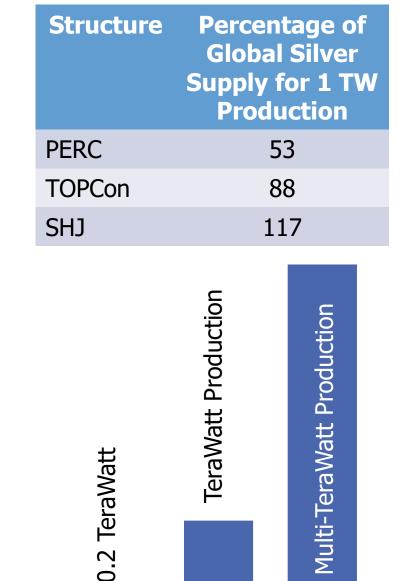
That is not feasible...





Ag Supply

Newer technologies use more silver.



2030

2020

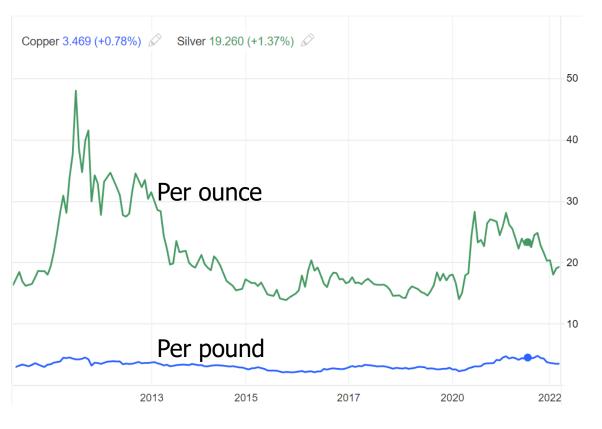
opportunities related to silver, indium and bismuth consumption", Energy Environ. Sci., 2021,14, Y. Zhang, M. Kim, L. Wang, P. Verlinden and B.Hallam (2021) "Design considerations for multiterawatt scale manufacturing of existing and future photovoltaic technologies: challenges and 5587-5610 DOI 10.1039/D1EE01814K

2050



Cost Comparison

Cost of Silver has increased 67% over the past 6 years and pricing is volatile



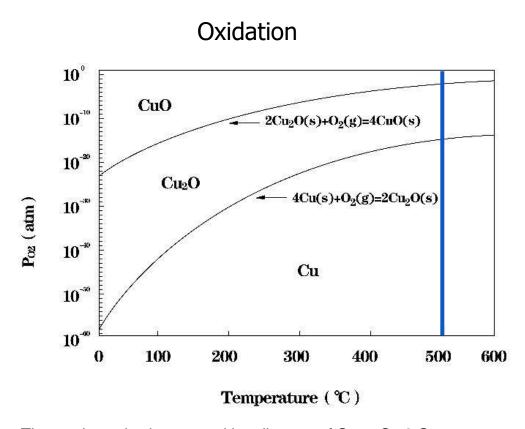
Copper 1/100th the cost of silver

So

- 300 GW Production
- ~10X increase in scale in 10 years
- Most of this CAPEX has not depreciated
- ~90% is screen printed with furnace
- 1 TW by 2030
- Screen printing with furnace is scalable



Why Not Copper? (Or what do we need to overcome?)



Thermodynamic phase transition diagram of Cu to Cu 2 O or CuO

Shang, Shengyan & Kunwar, Anil & Wang, Yanfeng & Yao, Jinye & Ma, Haitao & Wang, Yunpeng. (2018). Influence of Cu nanoparticles on Cu 6 Sn 5 growth behavior at the interface of Sn/Cu solder joints. 10.1109/ICEPT.2018.8480619.

Diffusion

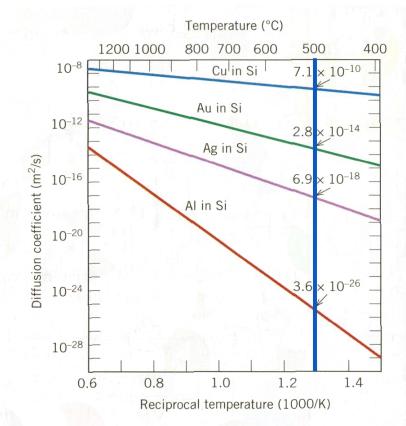
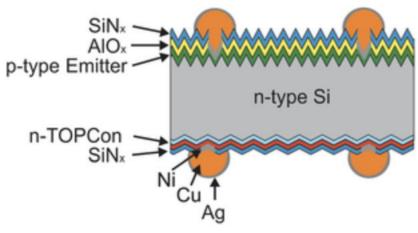


Figure 7.12 Logarithm of D-versus-1/T (K) curves (lines) for the diffusion of copper, gold, silver, and aluminum in silicon. Also noted are D values at 500° C.

Callister, W.D., Rethwisch, D.G., Materials Science and Engineering, 9th Edition, 2014, John Wiley and Sons



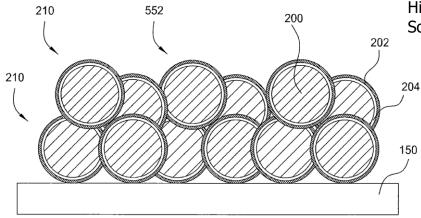
Copper SOA



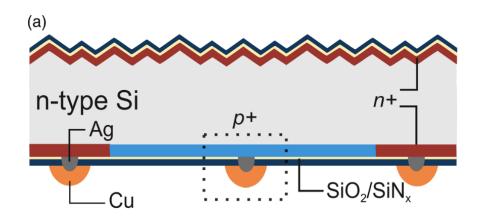
Plating

Grübel B, Cimiotti G, Schmiga C, et al. Direct contact electroplating sequence without initial seed layer for bifacial TOPCon solar cell metallization. *IEEE J Photovolt*. 2021;**11**(3):1-7.

doi:10.1109/JPHOTOV.2021.3051636



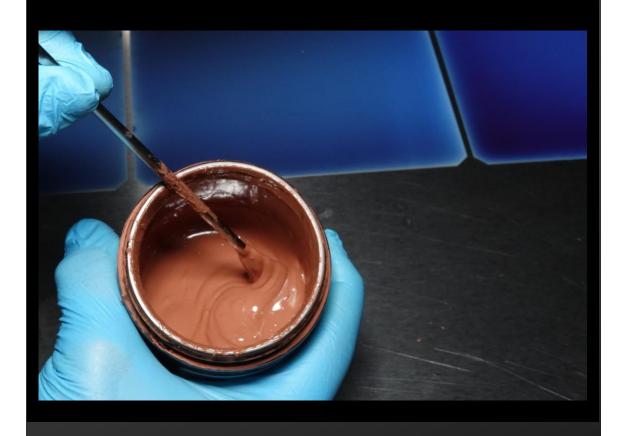
Gee, James, M (2011) Copper Paste Metallization for Silicon Solar Cells, European Patent EP 2 625 722 B1



Chen, N., D. Rudolph, C. Peter, M. Zeman, O. Isabella, Y. Rosen, M. Grouchko, O. Shochet, V. D. Mihailetchi (2023) "Thermal Stable High-Efficiency Copper Screen Printed Back Contact Solar Cells", Solar RRL, **7**(2) DOI https://doi.org/10.1002/solr.202200874

But All of these use silver





The Solution

CuBert[™] – Drop-in Replacement for Silver Pastes

CuBertTM

- No changes to processing.
- No new equipment to add.

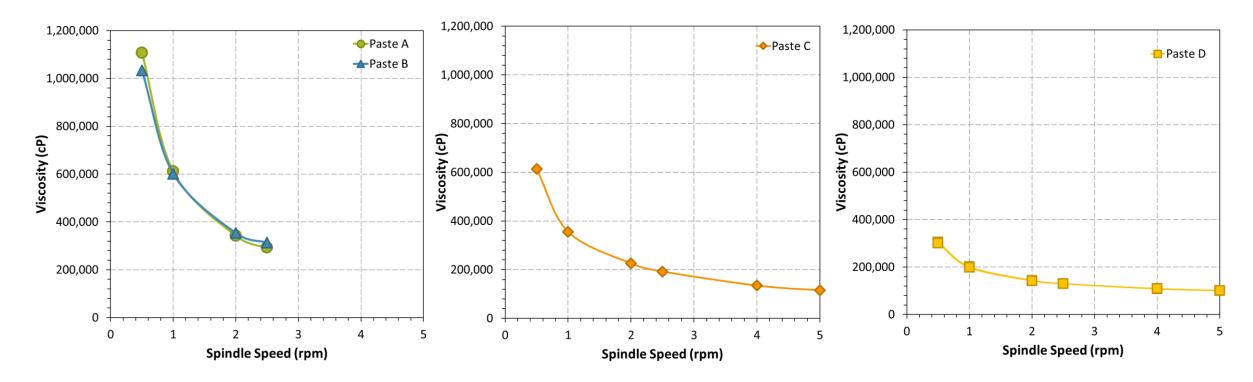
Screen Printable with the same printing technology used in the industry.

Air Fired in the same belt furnaces used in the industry.

Performance. Functional devices after firing at temperatures up to 600 °C.

Durability. Demonstrated stable pFF for 1000 hours at 200 °C, initial module damp heat.

Paste Rheology



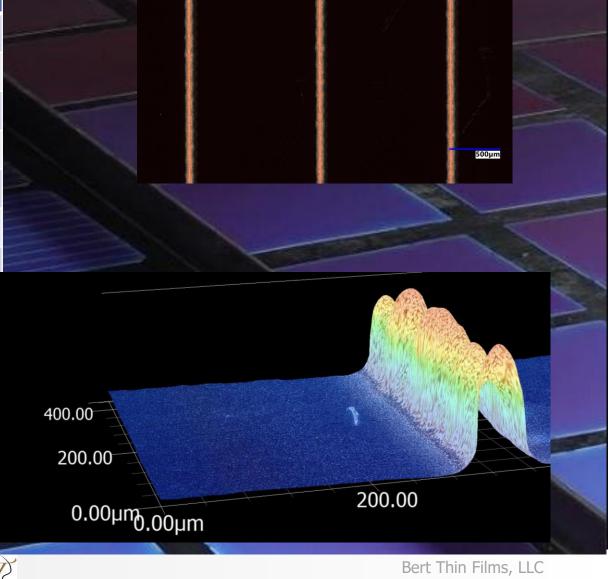


Viscosity can be adjusted.

Brookfield Ametek HB Cone and Plate Viscometer with CPA-52Z Spindle.

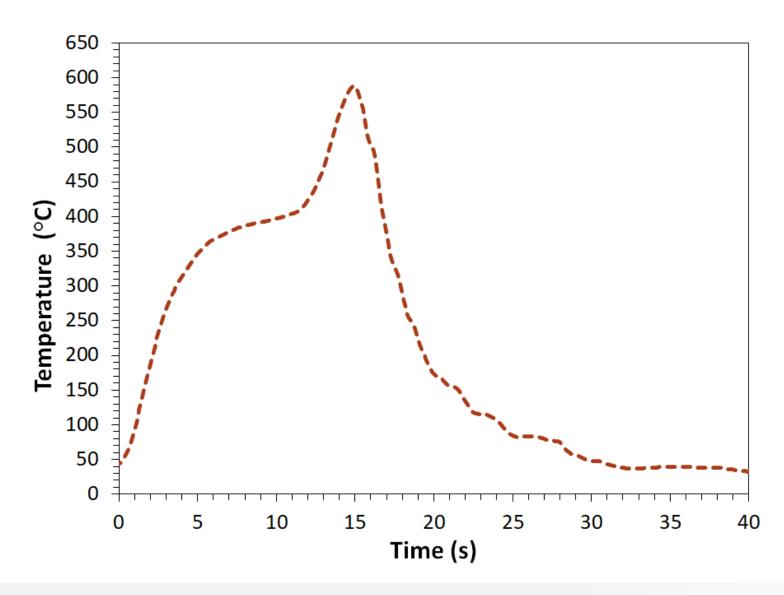
Screen Printing Parameters

Screen Parameter	Value
Mesh	400-500 mesh, 18 μm wire
Screen tension	16-19 N/cm
Emulsion thickness	12-20 μm
Print gap	1.25-2.0 mm
Print speed	50-150 mm/s
Squeegee pressure	8-10 kg
Squeegee durometer	70-80

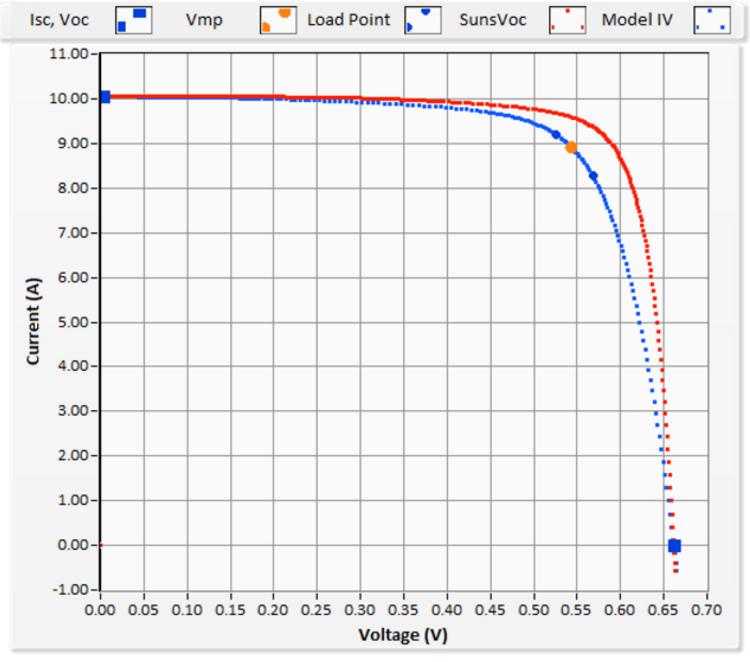




Firing Profile

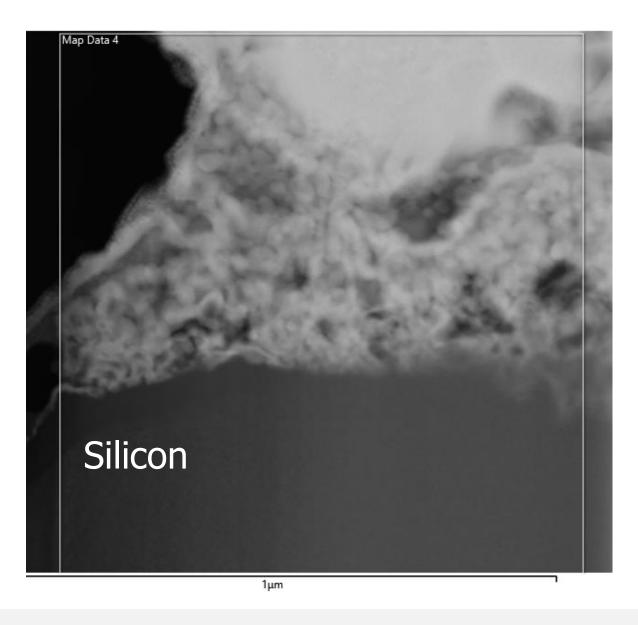


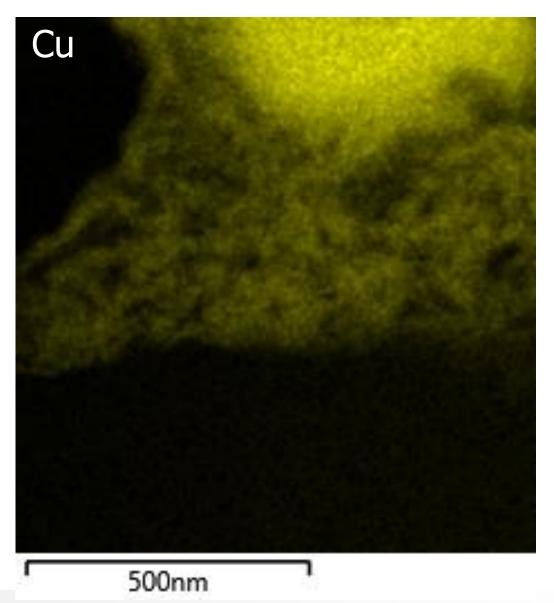
I-V Data

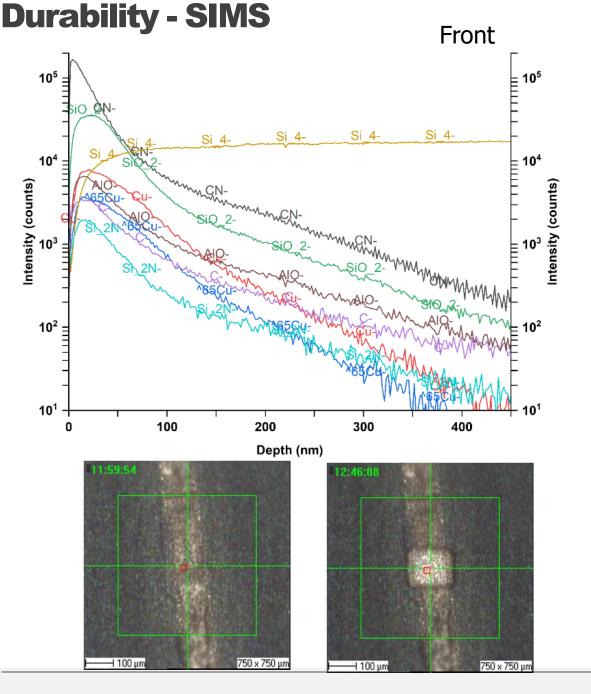




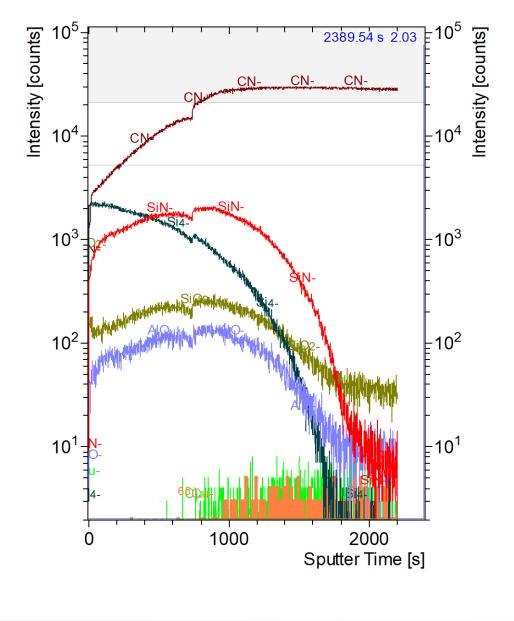
SEM Cross-section





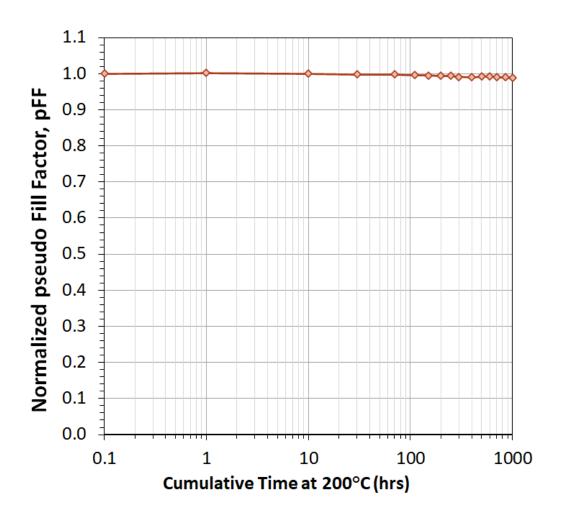


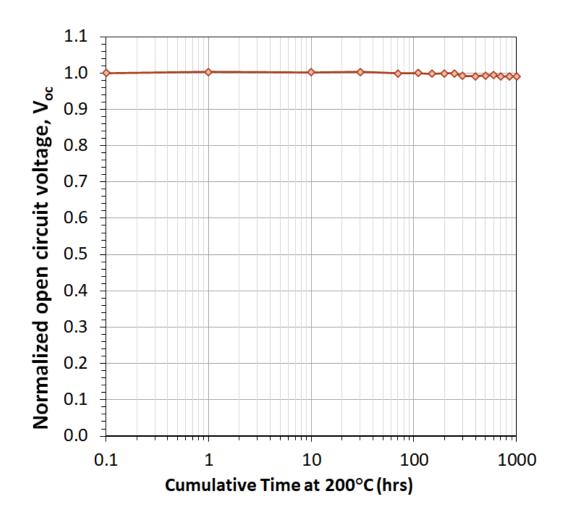




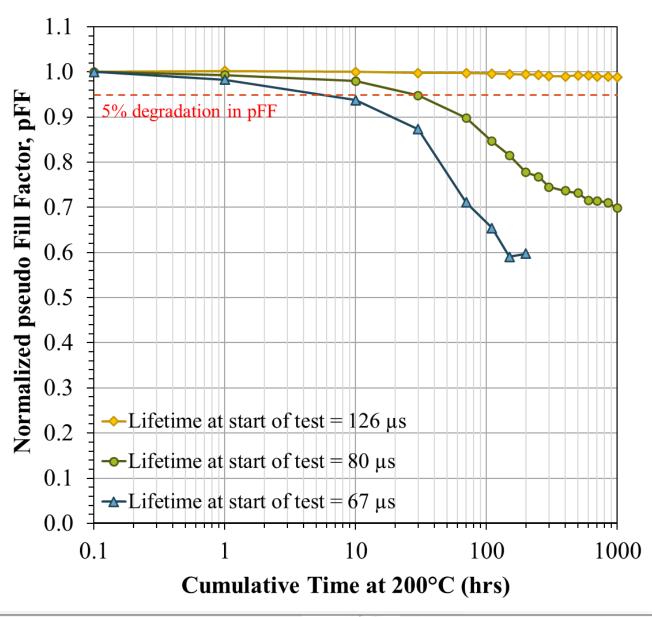


Durability (Dry testing) 200 °C 1,000 hrs





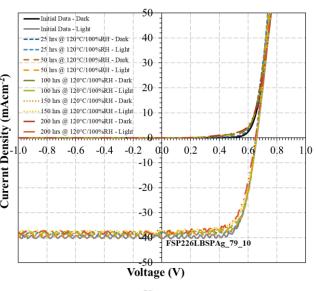
Discussion – Good vs. Bad Cell

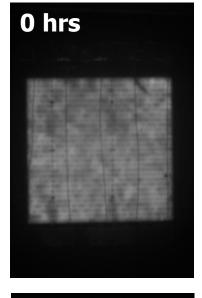


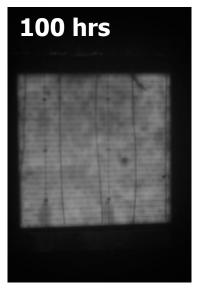
HAST: 120° C/ 100° RH/ 2 Bar (4 × 4 cm²)

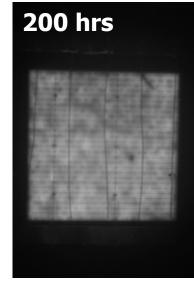
Good Cell:

After 200hrs Normalized iV $_{oc}$ = 1.00 Normalized pFF = 0.93



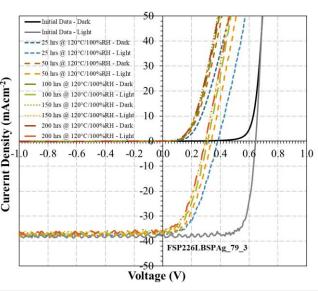






Bad Cell:

After 200hrs Normalized iV $_{oc}$ = 0.47 Normalized pFF = 0.64





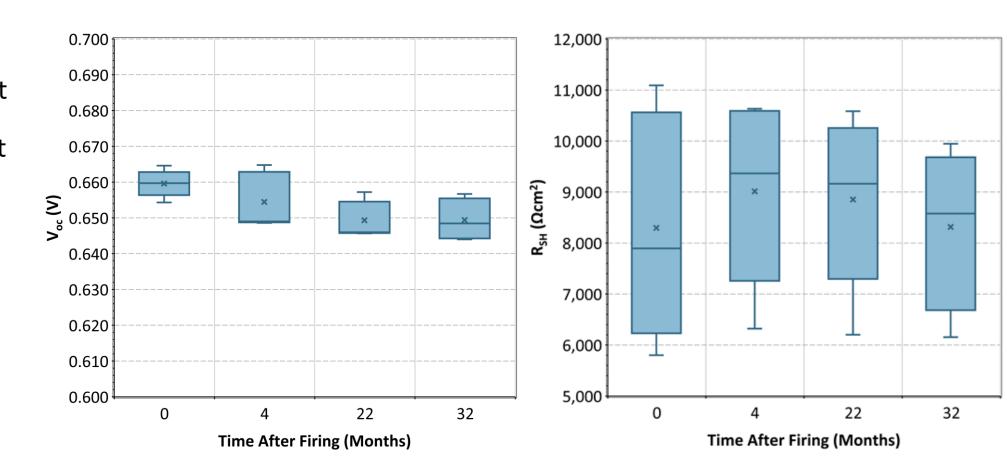




Durability (Ambient Storage)

Caveats

- 1. 5 cells
- 2. Measured on different IV systems
- 3. Measured by different people



Solderability (Solderable pads)





Conclusions

Copper Screen Printable Pastes for High Temperature Firing

- Copper paste no silver
 - Scalable
 - No cold storage
- Screen printed
- Fired in ambient air at 600 °C
 - Functioning device
 - Controlled etching
- Cell durability
 - Dry cell testing (200 °C, 1,000 hrs)
 - Encapsulated HAST (120oC, 100% RH, 2 Bar, 200 hrs)
 - Almost 3 years room storage
- Solderability
 - Initial results
- Next Steps

Thank You

Bert Thin Films, LLC

Ruvini Dharmadasa, PhD Kevin Elmer, Apolo Nambo, PhD

University of North Carolina Charlotte

Aba Ebong, PhD Sandra Huneycutt Donald Intal

- Thad Druffel
- **1** +1 502 338 6476
- thad@bertthinfilms.com
- http://www.bertthinfilms.com

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